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|--|------------|--------|-----------------|----------|----------------------------------|
| U.S. UTILITY Patent Application | | | | | |
| 102 103 | 120 | 0.17.1 | PATENT DRAWINGS | | |
| SCANNED | TM3 | J. B. | | | |
| APPLICATION NO. | CONT/PRIOR | CLASS | SUBCLASS | ART.UNIT | EXAMINER |
| 09/665940 | F | 216 | 438 | 710 | 1746 1765 - J. Miller Enonini |
| APPLICANT: Chisato Koshimizu Kazunori Nagahata | | | | | |
| BEST AVAILABLE COPY | | | | | |
| Plasma Processing apparatus and plasma processing method | | | | | |
| PTO-2040 12/99 | | | | | |

ISSUING CLASSIFICATION

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3) *Enzels Gmee.* | *Rips Gmee.* | *Print Fl.* | *Print Gmee.*

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